



LuxNIL® P276-U

High refractive index UV curable dispersion in PGMEA

FEATURES: High Refractive Index, EXCELLENT adhesion to plastic and glass substrates, OPTICALLY Clear

PRODUCT DESCRIPTION:

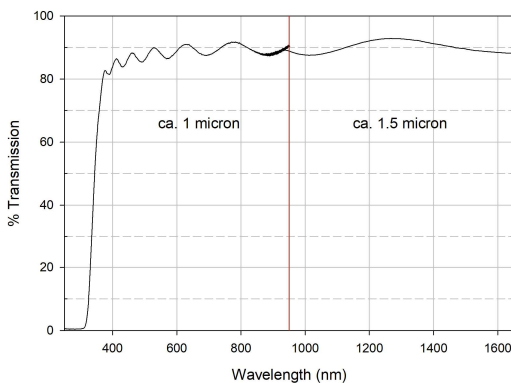
- LuxNIL® P276-U is a UV-curable inorganic organic dispersion in PGMEA that is suitable for AR/VR/MR applications.
- Base chemistry: Inorganic nano particles in acrylate binder.

PRODUCT USE:

- Diffractive Optical Elements (DOE)
- AR/VR/MR
- Photo Nano-Imprint Lithography (P-NIL)

LuxNIL® P276-U UV-VIS and NIR spectra

air reference, no correction for surface reflections



GENERAL USAGE INFORMATION:

Storage: After receipt in amber HDPE bottles, room temperature storage (15-30°C) in the original container is required.

TYPICAL PROPERTIES

Uncured resin

Solid content:	50%
Viscosity at 25 °C, mPa.s or cps	2-4
Shelf life (20 - 30°C):	6 months
Pot life or working life (20 - 30°C):	3 months

Cured film

Shrinkage (volume, %)	<1
Glass transition temperature (tan delta DMA)	104°C

Refractive index of cured film (25 °C)

@589 nm

1.80

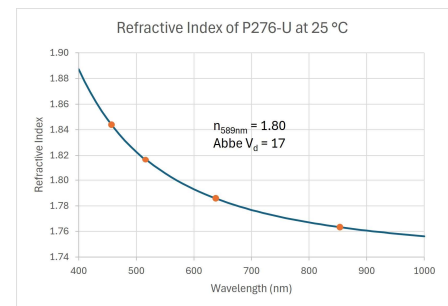
LuxNIL® P276-U optical properties

LuxNIL® P276-U RI vs wavelength

Properties	LuxNIL®P276-U
n_{589}	1.80
Transmission* [§]	89%
Haze*	0.2%
Clarity*	100%

*1 micron film on borosilicate glass.

§No correction for surface reflection



Operating temperature:

-40 to 100 °C

PROCESS FLOW



APPLICATION NOTES:

PROCESS:

- 1) Coating step for film forming: LuxNIL® P276-U is used as a nano imprint lithography resin. LuxNIL® P276-U can be applied by spin coat, or roll coat, etc.
- 2) Solvent removing step: after coating, heat is applied at 80 to 100 °C for 60 sec to remove PGMEA.
- 3) Nano-imprint-lithography: replication of nano features with a working stamper is conducted,
- 4) UV cure: UV cure to fix the nano features
- 5) Working stamp is removed
- 6) Final heat conditions at 150 °C for 4 hrs after imprint step will help remove all residual solvent and full refractive index can be obtained.

Coating thickness for LuxNIL® P276-U: 700 to 2000 nm

PRE-CURE (for solvent removal): 80 to 100 °C for 60 sec

UV CURING CONDITIONS:

*Metal halide/medium or high Mercury UV: UV-A (320-400 nm), intensity: 100-1,000 mW/cm²

*or LED-365 nm, UV light intensity: 100 to 1,000 mW/cm²

LuxNIL® P276-U should be cured between two substrates or in an inert atmosphere. If cured in air, the integrity of the film is reduced.

RECOMMENDED UV Conditions: LED-365 nm, 250 mW /cm² x 100 to 200 sec. Cure is done between 2 substrates or in an inert atmosphere.

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Addison Clear Wave Coatings, Inc., 3555 Legacy Blvd, St. Charles, IL 60174 USA

Tel: +1 630-444-1658, AddisonCW.com